

AMENDMENTS TO THE CLAIMS

1. (Withdrawn) A liquid crystal display (LCD) device comprising:
 - a first substrate defined by first and second regions;
 - a storage capacitor electrode and a gate electrode respectively formed in the first and second regions of the first substrate;
 - a single gate insulating layer formed on an entire surface of the first substrate so that the single gate insulating layer in the first region is thinner than in the second region;
 - a semiconductor layer and source and drain electrodes deposited on the single gate insulating layer of the second region;
 - a conductive layer formed on the single gate insulating layer of the first region;
 - a pixel electrode electrically connected to the drain electrode and the conductive layer;
 - a second substrate opposite to the first substrate; and
 - a liquid crystal layer formed between the first and second substrates.
2. (Canceled)
3. (Withdrawn) The LCD device as claimed in claim 1, wherein the gate insulating layer of the first region has a thickness in a range of about 100Å~4000Å.
4. (Withdrawn) The LCD device as claimed in claim 1, wherein the first region is a storage capacitor region, and the second region is a thin film transistor region.
5. (Withdrawn) The LCD device as claimed in claim 1, wherein the second substrate further includes:
 - a plurality of color filter patterns for displaying colors;
 - a black matrix for dividing the respective color filter patterns and for shielding light; and
 - a common electrode for applying a voltage to the liquid crystal layer.
- 6-14. (Canceled)
15. (Currently Amended) A liquid crystal display (LCD) device comprising:
 - a first substrate;

a second substrate;
a liquid crystal layer formed between the first and second substrates;
a storage capacitor formed in a first region of the first substrate;
a thin film transistor formed in a second region of the first substrate;
a gate electrode for the thin film transistor and a storage capacitor electrode spaced apart from the gate electrode, both formed on the first substrate;
a first insulating layer formed on an entire surface of the first substrate except an upper portion of the storage capacitor electrode;
a second insulating layer formed on the first insulating layer and the storage capacitor electrode;
a conductive layer formed on the second insulating layer in the first region overlapping the storage capacitor electrode except both side portions of the storage capacitor electrode in the first region and formed of the same material as a drain electrode of the thin film transistor; and
a pixel electrode electrically connected to the conductive layer and a drain electrode ~~on~~ of the thin film transistor,
wherein the width of the conductive layer is shorter than the width of the storage capacitor electrode, and
wherein the storage capacitor is formed by overlapping between the conductive layer connected to the pixel electrode and the storage capacitor electrode connected to the gate line, and the only second insulating layer is disposed between the conductive layer and the storage capacitor electrode.

16. (Original) The liquid crystal display device as claimed in claim 15, wherein the second insulating layer has a thickness in a range of about 100Å~4000Å.

17. (Original) The liquid crystal display device as claimed in claim 15, further comprising a semiconductor layer formed above the second insulating layer in the second region and used as a channel of the thin film transistor.

18. (Previously Presented) The liquid crystal display device as claimed in claim 17, further comprising a source electrode and the drain electrode opposing each other and formed above the semiconductor layer.

19. (Canceled).

20. (Previously Presented) The liquid crystal display device as claimed in claim 18, further comprising an ohmic contact layer formed at an interface between the source and drain electrodes and the semiconductor layer.

21. (Previously Presented) The liquid crystal display device as claimed in claim 18, further comprising a passivation layer having a contact hole and formed on an entire surface including the conductive layer and the source and drain electrodes to expose upper portions of the drain electrode and the conductive layer .

22. (Previously Presented) The liquid crystal display device as claimed in claim 21, wherein the pixel electrode electrically connects to the drain electrode and the conductive layer through the contact hole.

23. (Original) The liquid crystal display device as claimed in claim 15, further comprising a plurality of Red (R), green (G), and blue (B) color filter patterns formed on the second substrate opposite to the first substrate.

24. (Original) The liquid crystal display device as claimed in claim 23, further comprising a black matrix of a light-shielding film for preventing light from being transmitted to a region other than the pixel electrode and formed on the first substrate and formed among the color filter patterns.

25. (Original) The liquid crystal display device as claimed in claim 24, further comprising a common electrode for applying a voltage to a liquid crystal layer and formed on the entire surface including the black matrix and the color filter patterns.

26-41. (Canceled)